Quantum Coherence of Image-Potential States

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The quantum dynamics of the two-dimensional image-potential states in front of the Cu(100) surface is measured by scanning tunneling microscopy and spectroscopy. The dispersion relation and the momentum resolved phase-relaxation time of the first image-potential state are determined from the quantum interference patterns in the local density of states at step edges. It is demonstrated that the tip-induced Stark shift does not affect the motion of the electrons parallel to the surface.

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The image-potential states are model states for the study of electronic interactions of electrons at surfaces, a topic that has far reaching consequences for many surface processes. The self-interaction of electrons near metallic surfaces gives rise to eigenstates which are confined along the surface normal by the classical image potential on the vacuum side of the crystal surface and by the band structure of the crystal on the other side [1]. The lifetime of electrons injected or excited into an image-potential state is limited mainly by their interaction with bulk electrons. This has been studied in great detail in recent years by energy- and time-resolved two-photon photoemission spectroscopy (2PPE) [2–5]. Theoretical understanding of the involved electron-electron scattering processes has established that the lifetime of image-potential-state electrons is determined by interband scattering with bulk electrons and by intraband contributions [3,6].

The high local density of states (LDOS) of the image-potential states near the surface makes them accessible to scanning tunneling microscopy (STM). They appear at rather high sample bias voltages of 4–8 V. The electric field between tip and sample induces a Stark shift of the eigenenergies to higher values. Interest in image-potential states modified by the presence of an STM tip has focused so far on the fact that the energetic positions of the states are sensitive to the electronic structure of the surface [7,8].

Spectroscopy of image-potential states by STM has been used to achieve chemical contrast on the nanometer scale for metals on metal surfaces, e.g., Cu on Mo(110) [8] or Fe/Cr surface alloys [9]. In this Letter, we present for the first time STM measurements of the dynamical properties of the image-potential states in front of the surface. Because of elastic scattering at point defects and step edges of the electrons injected into these states, modulations of the LDOS emerge. Using scanning tunneling spectroscopy (STS), we determine the energies for the first four image-potential states as well as the dispersion relation and the phase coherence length of the $n = 1$ Stark-shifted image-potential state on Cu(100). This opens up the possibility to study these quantities locally in nanostructures. In the case of surface state electrons at metal surfaces the local dynamics has been studied by STS in detail [10–13]. The results show a good agreement between photoemission and STS experiments on the one side and theory on the other side [12,13]. A similar comparison is missing in the case of image-potential states.

We used a Cu(100) single crystal sample, carefully prepared by sputtering and annealing cycles in UHV (base pressure $1 \times 10^{-10}$ mbar). After cleaning, the sample was transferred in situ into a homebuilt STM operating at 6 K. Spectroscopic measurements were performed using a lock-in technique with a modulation of the sample voltage of 10–30 mV$_{\text{RMS}}$ at a frequency of 4.5 kHz. All bias voltages $V$ are sample potentials measured with respect to the tip.

Figure 1(a) shows a typical STM image of an artificially created step edge. The upper half is a topographic image and the lower half shows the simultaneously acquired $dI/dV$ map taken at the same bias voltage. It reveals the quantum interference pattern of the $n = 1$ image-potential state created by elastic scattering of the electrons injected by the tip into the image-potential state. Circular standing waves were also observed at point defects (not shown here). We will later present a detailed analysis of these patterns leading to the dispersion relation and the momentum resolved linewidth of the $n = 1$ Stark-shifted image-potential state.

The energies of the Stark-shifted image-potential states can be measured using $z(V)$ spectroscopy as shown in Fig. 1(b). For this experiment the feedback loop is kept active while sweeping the bias voltage. To maintain a constant current the tip is retracted with increasing bias voltage. It reveals the quantum interference pattern of the $n = 1$ image-potential state created by elastic scattering of the electrons injected by the tip into the image-potential state. Circular standing waves were also observed at point defects (not shown here). We will later present a detailed analysis of these patterns leading to the dispersion relation and the momentum resolved linewidth of the $n = 1$ Stark-shifted image-potential state.

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FIG. 1. (a) Upper half: STM topography of an artificially created step on Cu(100) taken at 5.2 V bias voltage. Lower half: $dI/dV$ map of the same place at the same bias voltage. The image-potential-state electrons reflected at the step edge create a density modulation which appears as a standing wave pattern in the $dI/dV$ map. (b) Measured $z(V)$ curve on a terrace of Cu(100) using two different tunneling currents of 0.1 and 1.0 nA. We observe up to four image-potential states in the electric field of the STM tip. The measured increments in the tip-sample distance are labeled $\Delta z_n$.

$$E_n = eV_n - \phi,$$

where $\phi = 4.6$ eV [5] is the work function of Cu(100) and $e$ the elementary charge. Note that the states appear above the vacuum level of the substrate, but nevertheless they are bound in the $z$ direction by the tip and crystal potential, respectively. From the absence of any features in $z(V)$ below 3 V we identify the step at $V = 4.7$ V as the state $n = 1$. The energies are considerably larger compared to the unperturbed states which form a Rydberg series below $E_{\text{vac}}$ starting at $-0.6$ eV [3,14].

As can be seen from a comparison of the two spectra shown in Fig. 1(b), the states shift to higher energies for higher tunneling currents due to the decreased tip-sample distance. Measurements with different tips, i.e., tips that have been modified by field emission and gentle dipping into the surface, reveal a dependence of the energy levels on the tip properties which is stronger for the higher states. While the $n = 1$ state remains at a bias voltage of $4.7 \pm 0.1$ V, we observe the higher states to shift by as much as $0.5$ V ($n = 2$) and $0.9$ V ($n = 3$). This yields a much stronger dependence of the energy levels on tip properties than on tunneling conditions, i.e., the current at which the $z(V)$ spectroscopy is performed.

To understand these findings we performed model calculations using a one-dimensional potential as introduced by Chulkov et al. [14]. This potential reproduces the Rydberg series of the image-potential states and the positions of the projected band edges at the $\Gamma$ point ($k_{||} = 0$) in the Cu(100) surface Brillouin zone. We integrated the Schrödinger equation in real space employing the model potential for a 25 layer crystal. The influence of the tip is modeled by adding as a function of the bias voltage a linearly increasing potential to the image potential of the crystal reaching from the point $z_{\text{im}}$ (see Ref. [14]) to the point $z_{\text{im}} + z$ where $z$ is the tip-sample distance. A similar ansatz has been used in Ref. [15]. Since the change in tip-sample distance is given by the plateaus $\Delta z_n$ [Fig. 1(b)] we use $z = \Delta z_n + z_0$ and treat $z_0$ as the only adjustable parameter in the model assuming equal work functions of tip and sample. This choice was made in favor of discussing the average electric field in the junction [7] since it allows one to separate $V$ as an externally controllable parameter from details of the potential. The model potential and the probability distribution of the resulting wave function are shown in Fig. 2(a). Figure 2(b) shows schematically the resulting energy level diagram. In such a simple model, the energies $E_n$ of the image-potential states in the electric field of the STM tip are reproduced for all $n$ observed. This is shown in Fig. 2(c), where the calculated energies $E_n$ are plotted as a function of the applied bias voltage for $z_0 = 22.5$ Å corresponding to the measurement with a tunneling current of 0.1 nA. The agreement is excellent. To reproduce the energy levels for the measurement at a current of 1 nA $z_0 = 19.5$ Å is found. We emphasize that there is no need for an $n$-dependent “surface-correlation parameter” as was employed earlier [7]. To arrive at the expected smaller $z_0$ values of 8 to 10 Å [16] one has to improve the treatment of the tip electrode. The detailed inclusion of the image potential at the surface of the tip in a calculation using two Cu(100) model potentials facing each other yielded $z_0$ values which were 3–5 Å lower than the ones found above. On the other hand, the radius of curvature $R$ of the tip can be neglected. Only for unrealistically sharp tips with $R = z$ the potential near the tip will fall off appreciably more quickly than the linear potential. We conclude that to explain the variation of the $E_n$ with different tips the contact potential and not the tip radius is the decisive quantity. From the experimental point of view it is quite likely that the tungsten tip is coated with copper, since it is frequently prepared by slightly dipping it into the surface. Both, the composition and the morphology of the very end of the tip can lead to a lower work function compared to that of the Cu(100) surface, which can be compensated by a reduced $z_0$.

In the following, the dynamics of the image-potential-state electrons in front of the surface will be discussed in...
Elastic states with oscillations reveal the parabolic dispersion relation of the density oscillations as shown in Fig. 3(a). The density curves are represented as a grey scale map, where horizontal line sections are the energy resolved electron density oscillations as shown in Fig. 3(a). The density oscillations reveal the parabolic dispersion relation of the state with \( E_1' = 4.7 \pm 0.1 \) eV and \( m' = (0.8 \pm 0.1)m_0 \) [Fig. 3(c)]. However, with the help of the calculations presented above, the influence of the tip on the dispersion of the image-potential state can be corrected for. Since the data are collected in open feedback mode, i.e., the distance between tip and sample is kept constant, one needs only to compensate for the shift of the energy at \( \Gamma \) with changing electric field during the bias voltage sweep. The dependence of the state’s energy on the applied bias voltage close to \( E_1' \) is approximately linear. From the calculations shown in Fig. 2(c) we get \( dE_1/dV = 0.12 \). Using this correction, we obtain an effective mass of \( m^* = m'/(1-0.12) = (0.9 \pm 0.1)m_0 \). This agrees perfectly with the effective mass \( m^* = 0.9m_0 \) of the \( n = 1 \) image-potential state as determined by 2PPE [5]. Similarly, we find an effective mass of \( n = 2 \) state of \( m^* = (1.0 \pm 0.1)m_0 \). An increase in the effective mass for \( n = 2 \) was also observed by 2PPE [18].

The standing wave pattern decays with an increasing distance from the step edge due to geometric factors and to a loss of coherence [11]. The decaying LDOS pattern formed by the image-potential states near a step edge can be described by
FIG. 4. Phase coherence lengths of the interference pattern at a step edge converted into linewidths $\Gamma(E)$. Solid symbols are the data taken by STM, and the solid line is a linear fit to them; open symbols represent linewidths determined by 2PPE measurements from Ref. [3].

$$\rho = L_0[1 - re^{-\pi/4L_0j0(2k||r)]}, \quad (2)$$

where $L_0$ is an overall proportionality constant, $r$ the reflectivity of the step edge, $L_0$ the phase coherence length, $k||$ the wave vector of the electron parallel to the surface plane, and $j0$ the Bessel function of zeroth order.

To determine the lifetime of an electron in the $n = 1$ image-potential state we have analyzed quantitatively the quantum interference pattern and measured the phase coherence length $L_0$ as a function of energy on large defect free terraces. The scattering processes thus studied are those experienced in the absence of any defects [11,13]. Inelastic scattering at the step edge leads to a reduced overall amplitude of the standing waves described by $r$ in Eq. (2). Care was taken to account for instrumental broadening through the applied bias modulation when measuring the $d\Gamma/dV$ signal which also induces a decay of the wave pattern [11]. The obtained phase coherence lengths of 75–85 Å are converted into linewidths through $\Gamma(E) = h^2k/(2\pi^2L_0(E))$ by using the measured $k$ and $m^*$ according to the dispersion relation (Fig. 3). The results shown in Fig. 4 agree excellently with the $k$-resolved linewidths found by 2PPE measurements [3]. In agreement with theory, we find $\Gamma(E)$ to increase linearly with energy, although the rate of $d\Gamma/dE = 32$ meV/eV obtained from the fit in Fig. 4 is lower than the theoretical prediction [3]. The comparison of our results with the 2PPE measurements demonstrates that the presence of the tip does not alter substantially the dynamical properties of electrons in the image-potential states. Although the $n = 1$ state shifts by as much as 0.7 eV due to the presence of the electric field, it is still located near the center of the $\sim 6$ eV wide directional band gap of Cu(100). There is thus no significant change in the coupling to the bulk electrons, which is the main contribution to the linewidth.

In conclusion, we observed for the first time density modulations of image-potential-state electrons in the vicinity of steps and point defects on Cu(100). The quantum interference patterns allow us to determine the dispersion relation of the states which experience a Stark shift due to the electric field in the tunneling junction. Furthermore, we measured the phase coherence length of the electrons on clean terraces. Both the dispersion relation and the phase coherence length agree well with the results of nonlocal photoemission experiments. This shows that the motion of the electrons parallel to the surface is not noticeably affected by the field of the STM tip. Because of the local character of the measurement, the STM can therefore be used to study the dynamical behavior of image-potential-state electrons confined laterally to nanostructures and to characterize the scattering properties of surface defects and adsorbates.

[17] To enhance the contrast, the average value of each horizontal line has been subtracted.